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(12) **United States Design Patent** (10) **Patent No.:** **US D989,946 S**  
**Yokoi** (45) **Date of Patent:** **\*\* \*Jun. 20, 2023**

(54) **SANITARY MASK**  
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(72) Inventor: **Takanao Yokoi**, Aichi (JP)

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(73) Assignee: **Shirohato Co., Ltd.**, Aichi (JP)  
(\* ) Notice: This patent is subject to a terminal disclaimer.

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(\*\*) Term: **15 Years**  
(21) Appl. No.: **35/513,240**  
(22) Filed: **Jun. 21, 2021**

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(57) **CLAIM**

The ornamental design for a sanitary mask, as shown and described.

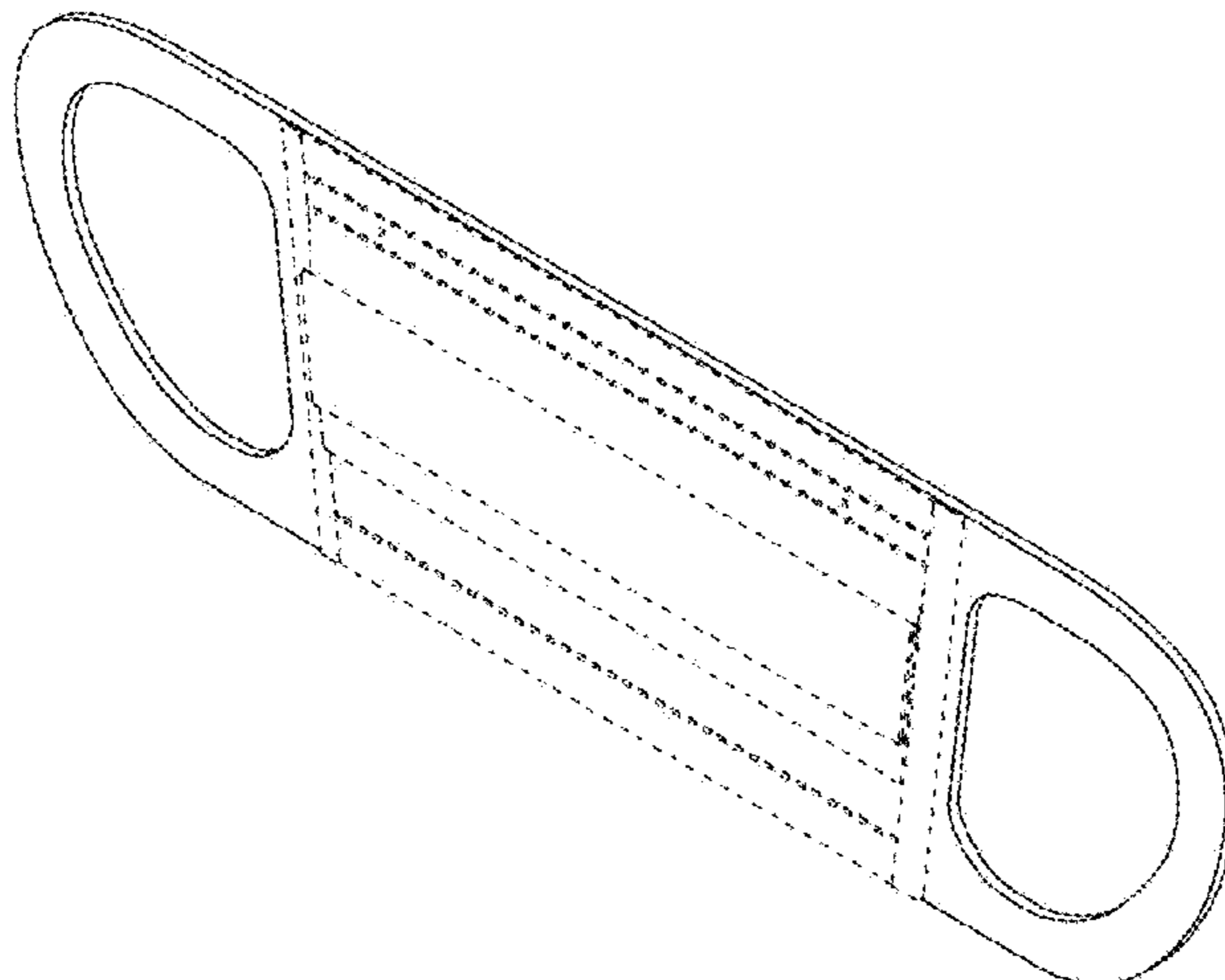
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(51) **LOC (14) Cl.** ..... **29-02**  
(52) **U.S. Cl.**  
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(58) **Field of Classification Search**  
USPC ..... D24/110.1, 110.2, 110.4, 110.5, 162;  
D29/108  
CPC ..... A41D 13/1107; A41D 13/1115; A41D  
13/1161  
See application file for complete search history.

**DESCRIPTION**

1. Sanitary mask  
**1.1** is a front view of a sanitary mask in accordance with the new design;  
**1.2** is a left side view of the sanitary mask of **1.1**;  
**1.3** is a right side view of the sanitary mask of **1.1**;  
**1.4** is a rear view of the sanitary mask of **1.1**;  
**1.5** is a top view of the sanitary mask of **1.1**;  
**1.6** is a bottom view of the sanitary mask of **1.1**;  
**1.7** is a perspective view of the sanitary mask of **1.1**;  
**1.8** is an enlarged cross-sectional view of the sanitary mask of **1.1**; and  
**1.9** shows the sanitary mask in an environment.  
The broken lines indicate portions of the sanitary mask that form no part of the claimed design; the enlarged cross-sectional view is sectioned vertically at the center of the front view.

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**1 Claim, 9 Drawing Sheets**



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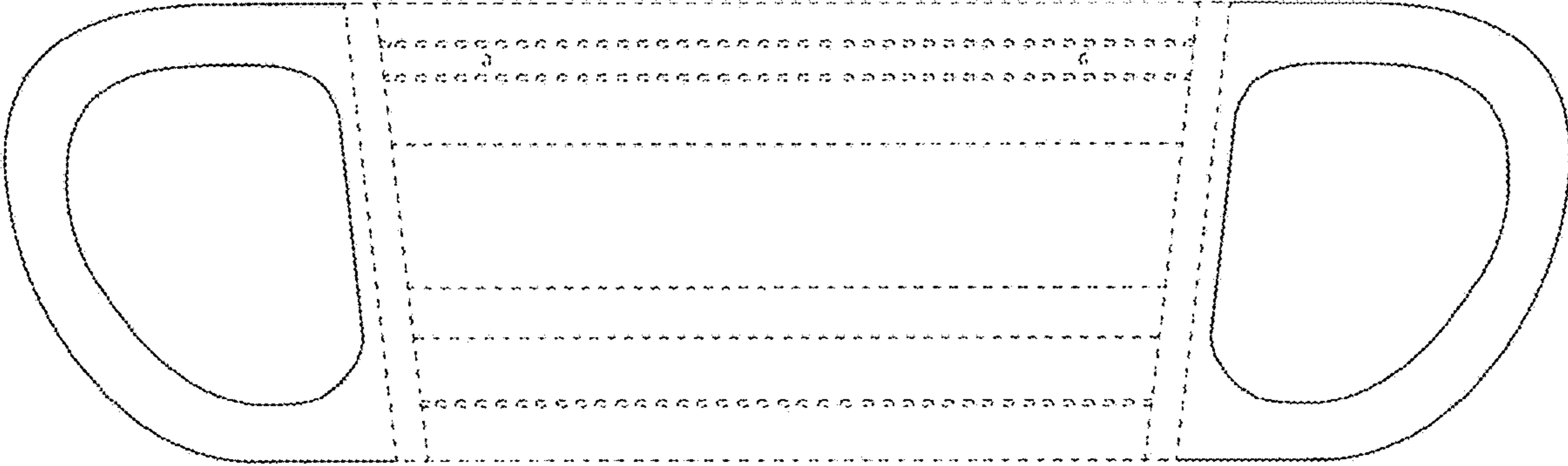
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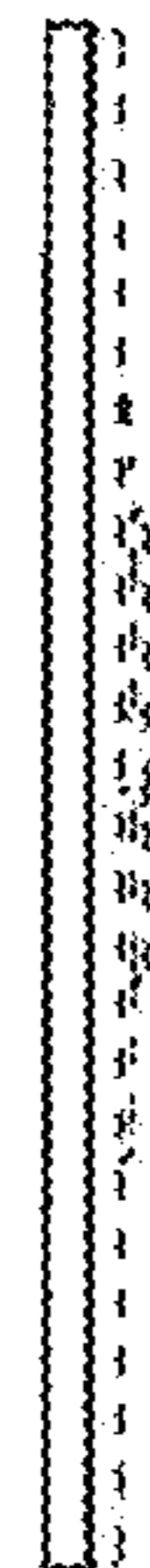
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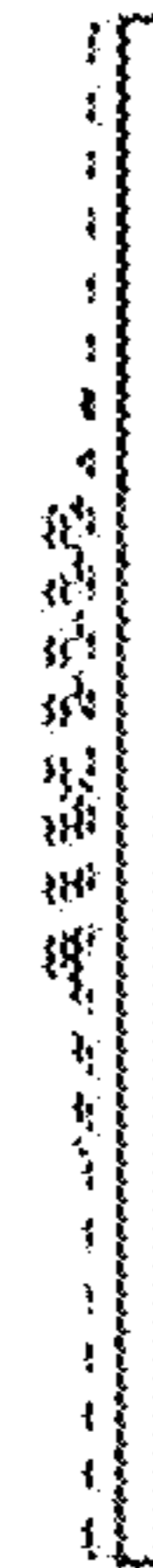
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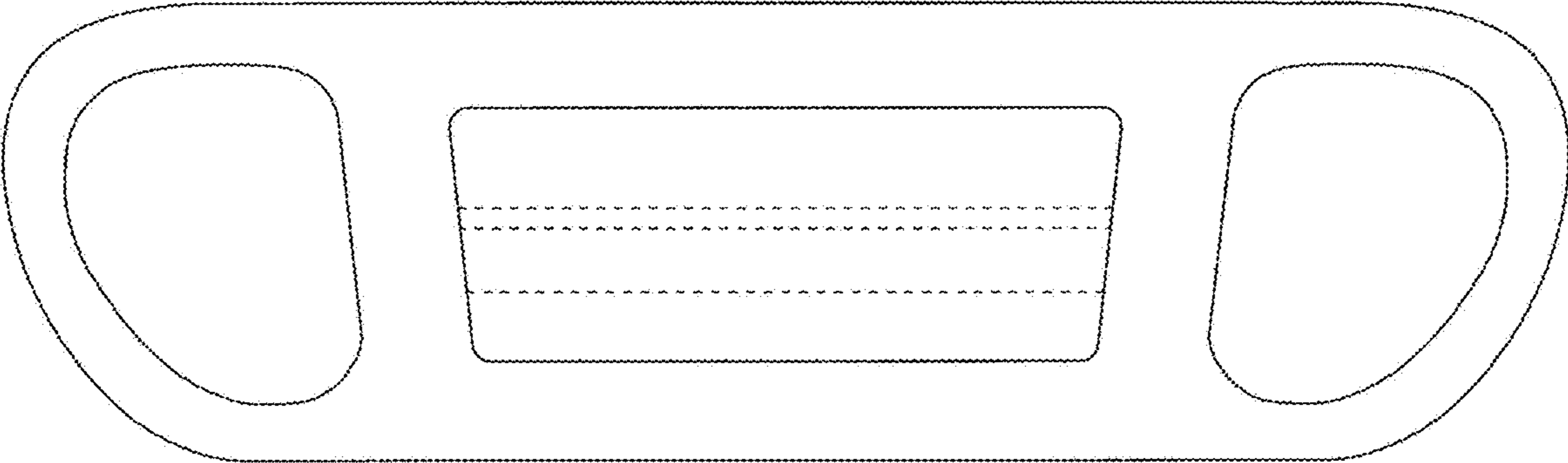
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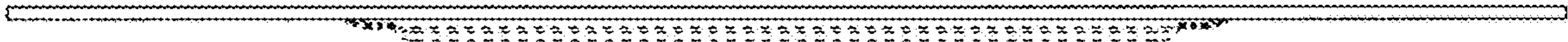
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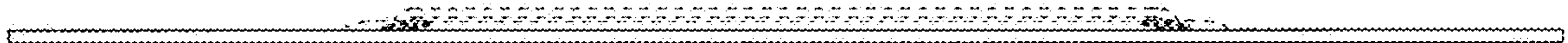
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1.5

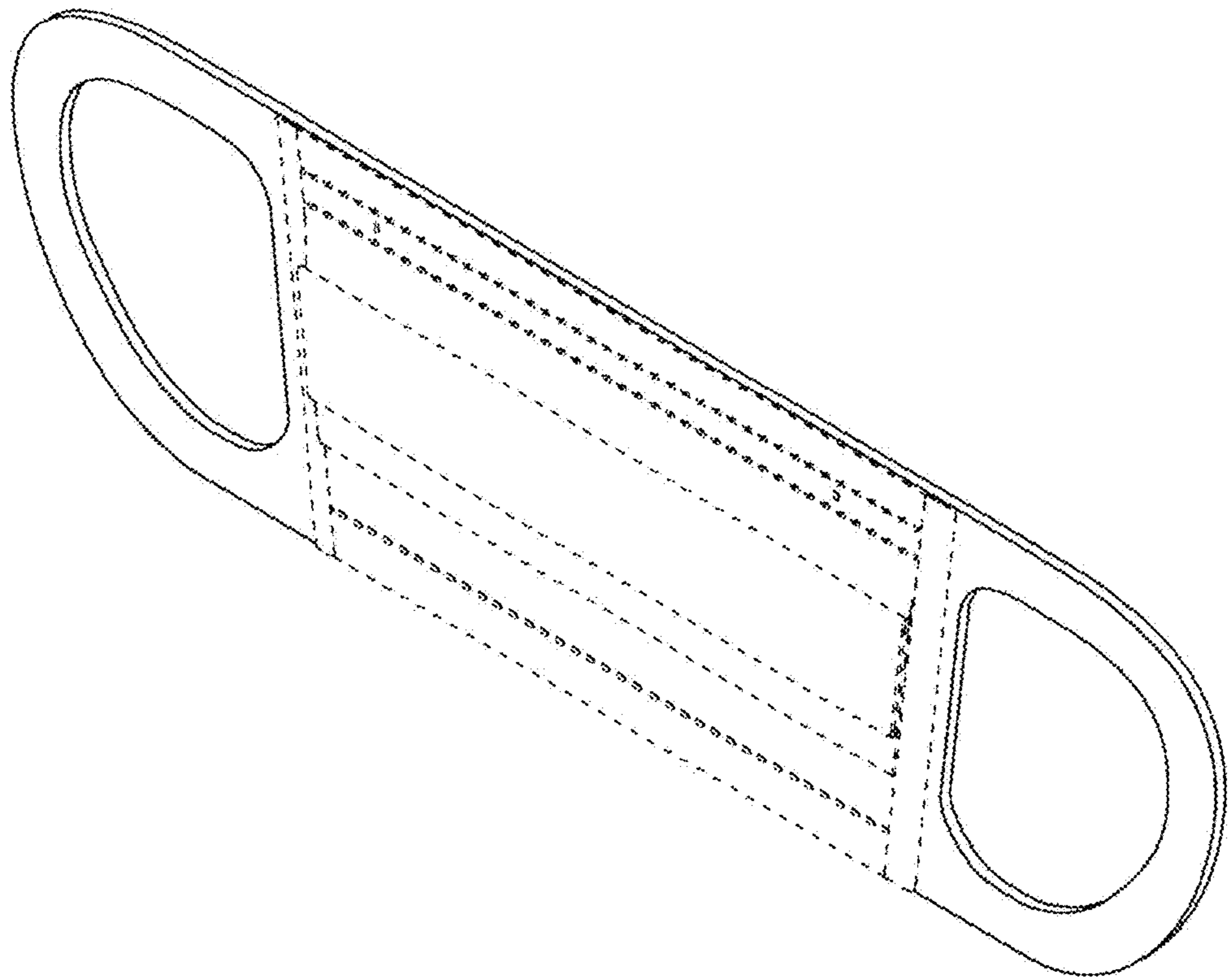


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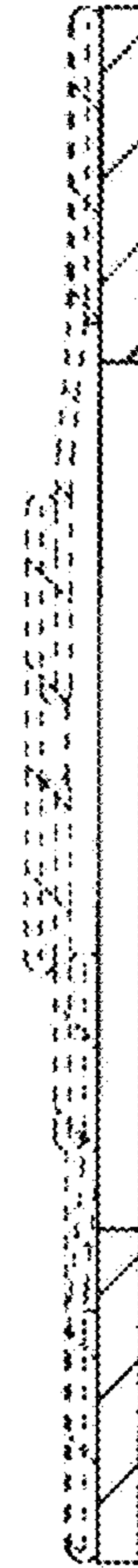




1.7



1.8



1.9

